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Input & Output Controlled GaN Power Amplifiers

Vince Mallette





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Ph.D. degree at the iRadio Lab, University of Calgary, Calgary, AB, Canada. He has authored or co-authored over 20 publications and holds 3 U.S. patents. His current research interests include high-efficiency radio frequency (RF) power amplifiers, monolithic microwave integrated circuit (MMIC) active and passive RF circuits and systems, and load-pull techniques. Mr. Dhar was a recipient of the Izaak Walton Killam Pre-Doctoral Scholarship, the AITF Doctoral

Scholarship, the Open Doctoral Scholarship, the Academic Excellence Award, and the Research Productivity Award Tushar Sharma (S'10) received the Ph.D. degree



from the University of Calgary, Calgary, AB, Canada, in 2018. In 2016 and 2017, he joined NXP Semiconductors, Chandler, AZ, USA, as a Research and Develop-ment RF Engineer to work in the field of gallium nitride technology evaluation and design for 5G base station applications. He is currently a Post-Doctoral Research Associate with Princeton Uni-versity, Princeton, NJ, USA. He has authored or to-authored over 20 refereed publications and

pending U.S. patents. His current research interests include high-efficiency broadband radio frequency (RF)/mmW power amplifiers, waveform engineering techniques, and active/passive load-pull techniques. Dr. Sharma was a recipient of the Izaak Walton Killam Pre-Doctoral

Scholarshin the Alberta Science and Innovation under 30 Future Leader Award, the AITF Doctoral Scholarship, the Alberta Transformative Talent Scholarship, the Academic Excellence Award, and the Research Productivity



degree in communications engineering from the École Sapérieure des Communications de Tunis. Ariana, Tunisia, in 2008, and the Ph.D. degree in electrical engineering from the University of Calgary, Calgary, AB, Canada, in 2013. He is currently with Ericsson Canada Inc., Ottawa, ON, Canada. He has authored or co-authored over 40 refereed publications and holds 4 patents. His urrent research interests include advanced nower

amplifier design and radio frequency (RF) front-end architectures for cellular base transceiver stations.

Damon G. Holmes (M⁺13) received the B.Sc and M.Sc. degrees from the University of Cal gary, Calgary, AB, Canada, in 2002 and 2005

He has gained over 15 years of industrial expe rience with Nortel Networks Wireless Infrastruc ture Group, Freescale and NXP Semiconductors Chandler, AZ, USA, where he is involved in transmitter architectures, advanced power amplifier design including Doherty, waveform shaping, and large-signal device modeling in support of cellular

and wireless communication technology. He currently manages the new technology integration design efforts for high-power macrocell application with NXP Semiconductors' Radio Power Solutions business unit. He holds 23 patents, awarded and pending,



He is currently an Application Engineer with the Focus Microwaves Group, Montreal, OC, Canada His current research interests include advanced load pull techniques for transistor characterization and RF system level design

Vince Mallette has over 12 years of experience in international sales, marketing, and strategic business development in test and measurement. He is cur rently the Director of Sales and Business Devel connent with Focus Microwanes Montreal OC Canada. His current research interests include global strategic sales and marketing initiatives and expan sion in new markets, as well as continued expansion among existing clients.



Fadhel M. Ghannouchi (S'84-M'88-SM'93-F'07) held several invited positions at several academic and research institutions in Europe, North America, and Japan. He has provided consulting services to a number of microwave and wireless commu nications companies. He is currently a Professor, Alberta Innovates/the Canada Research Chair, and the Founding Director of the iRadio Laboratory Department of Electrical and Computer Engineering, University of Calgary, Calgary, AB, Canada He has authored or co-authored over 650 publica tions. He holds 16 U.S. patents with 4 pending. His current research interest

include microwave instrumentation and measurements, nonlinear modeling of microwave devices and communications systems, design of power, and spectrum-efficient microwave amplification systems, and design of intelligen radio frequency (RF) transceivers for wireless and satellite communication





Waveform Engineering Concept



Reference : Low frequency waveform measurements: from theory to power amplifier design https://intranet.birmingham.ac.uk/eps/documents/public/emuw2/WTh01.pdf











Why Input Nonlinearity Analysis Needed?

- In Broadband design, it cannot be avoided
 - Better be explored and exploited
- Input nonlinearity degrades PA performances
 - Misconceived, need to be properly understood.
- Input nonlinearity could pave the way of understanding a true harmonic tuned broadband PA **IN PRACTICE**.



Source of Input Nonlinearity – Pathway to Input Waveform Engineering



 $V_{IN}(\theta) = V_1 \cos \theta$

 $v_{GS}(\theta) = V_{GS0} + V_1 \cos \theta + V_2 \cos(2\theta + \varphi_2)$ $v_{GS,\text{norm}}(\theta,\gamma,\varphi_2) = \frac{v_{GS}(\theta) - V_{GS0}}{V_1} \quad \gamma = V_2/V_1$ $=\cos\theta + \gamma\cos(2\theta + \varphi_2)$

 C_{gs} vs Vgs Variation











What controls γ and $\boldsymbol{\varphi}_2$?



Second Harmonic Source Pull

- The second harmonic source/input impedance determines the magnitude (γ) and phase difference (φ_2) between second and fundamental harmonic
- $\Box \ \gamma \text{ and } \varphi_2 \text{ changes as function of second} \\ \text{harmonic source pull and impacts the} \\ \text{input waveform at gate of the device} \\ \end{bmatrix}$
- This is turn impact the drain waveforms and achievable drain efficiencies of the active device under test



Input Waveform Engineering

□ Varying magnitude (γ) and phase difference (φ_2) between **second harmonic** and **fundamental** component at device input results in family of input waveforms



Family of Input Waveforms as function of Input Nonlinearity



Input–Output Controlled Power Amplifier Design







Impact of Input Non Linearity on Drain Waveforms



Impact of Input Nonlinearity on Performance – Class B



□ For combinations of γ and φ_2 , the conduction angle goes less than 180° and thus helping in decreasing overlap between current and voltage waveforms



Possibilities of achieving theoretical efficiency up to 85 % depending on magnitude of γ and φ_2



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Harmonic Tuned Classes Vs Input Non Linearity



- $\hfill \Box$ The maximum and minimum efficiency are function of γ and φ_2 and combination of output harmonics
- □ Class B/J/F shows big efficiency delta with input non-linearity, however Class F⁻¹ is relatively immune to it.





Input Output Waveform Engineered PA using Focus MPT/MPT Lite Tuners







Second Harmonic Source Pull Using MPT – Class B





- The maximum efficiency for Class B is a non short termination.
- There is an efficiency "null" region at the source which impact broadband design of harmonic tuned PAs.



Second Harmonic Source Pull – Class F





- □ Class F shows 90% measured peak efficiency with second harmonic control at input of an active GaN die
- □ Class F shows 30% efficiency delta as function second harmonic source sweep

Good area of design for Broadband application i.e. input controlled continuous Class F PA





Second Harmonic Source Pull – Class F-¹



- Efficiency Flatness over second harmonic source sweep. Immunity to input nonlinearities
- Broader design space for high efficiency broadband amplifier design







Broadband Input-Output Controlled PA

Second Harmonic Source Pull for Continuous Class F⁻¹ PA







Effects of 2nd harmonic tuning – Source & Load Tuning







Waveform engineering at mmW - Possible



67 GHz Vector LP Setup





Waveform engineering at mmW - Possible

• 110GHz Setup Using ZVA 5 mmozpie (200 mm ZD-2110 ZD-2110





Integrating DELTA tuners CM300



Front view

ISO view







Input-Output Controlled Harmonic Tuned PAs







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